

Press Release

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Nanonex at 53th International Conference on Electron, Ion, Photon Beam Technology and Nanofabrication (EIPBN '09), May 26 – May 29, 2009, Marco Island, FL.

Princeton NJ, May 29, 2009: Professor Stephen Y. Chou of Princeton University, founder of Nanonex Corporation, served as the Chairman of 53th EIPBN international conference. During the conference, Nanonex introduced its current research in laser assisted direct imprint technology. This technology is capable of direct “print” nanopatterns, planarizing rough surface and fill nanotrenches of hard materials through laser melting and imprinting. This project is partially supported by NIST-APT program.

About EIPBN Conference

The EIPBN Conference is recognized as the foremost international meeting dedicated to lithographic science and technology and its application to micro and nanofabrication techniques. The conference brings together engineers and scientists from industries and universities from all over the world to discuss recent progress and future trends.